

**Participants of the 2nd EMVA Business Conference
from 21st - 22nd April, 2004
in Budapest, Hungary
Status of June 01, 2004**



Name	Company/Organisation	Country
Name	Company / Organisation	Country
Ádám, Nagy	GE Lighting Tungfram	Hungary
Amir, Shlomo	Advanced Vision Technology (AVT)	Israel
Bako, Laszlo	AMISYS Ltd.	Hungary
Beising, Michael	SAC GmbH	Germany
Braggins, Don	UKIVA	United Kingdom
Bylek, Johann	Pennwell Corporation	Germany
Cohn, Michael	Parameter AB	Sweden
Colet, Philip	Coreco Imaging	Canada
Cucchetti, Ettore	Cognex Inc.	Germany
David Cochrane, David	DALSA	Canada
Diani, Marco	Image S SRL	Italy
Dierks, Friedrich	Basler AG	Germany
Drews, Kirsten	Siemens AG	Germany
Fodor, Peter	AnaLogic Computers Kft	Hungary
Fremmer, Markus	Matsushita Electric Works (Europe) AG	Germany
Friedrich, Michael K.	Volpi AG	Switzerland
G. Szabó, István	OPTIKA Mérnökiroda Kft.	Hungary
Geffe, Jürgen	Vision & Control GmbH	Germany
Gökstorp, Mats	IVP Integrated Vision Products AB	Sweden
Gruber, Bernhard	QUISS GmbH	Germany
Hauser, René	Photonfocus AG	Switzerland
Heinczinger, Robert	Ernst & Young Advisory Ltd.	Hungary
Heinol, Horst G.	ASENTICS GmbH & Co. KG	Germany
Hock, Manfred	EMVA	Germany
Holler, Horst	Laurin Publishing Company	Germany
Holton, Conard	Vision Systems Design	USA
Hoog, Steffen	National Instruments	Germany
Horvath, Zoltan	Falcon-Vision Rt	Hungary
Huenerfauth, Thomas	Matsushita Electric Works (Europe) AG	Germany
Jansen, Gabriele	ISRA VISION SYSTEMS AG	Germany
Jochum, Johannes	GIT Verlag	Germany
Justen, Jarmo	ORBIS OY	Finland
Karady, Gyuri	Barings Private Equity	United Kingdom
Karattup, Naren	E-Gits GmbH	Germany
Kawakami, Kazuyuki	Tokyo Electronic Industry Co.,Ltd.	Japan
Klinger, Matthias	Vision & Control GmbH	Germany
Köhalmi, Jozsef	Falcon Vision RT.	Hungary
Konaka, Hideaki	Tokyo Electronic Industry Co.,Ltd.	Japan
Laibarra, Begona	SQS	Spain
Lewerendt, Ingo	Allied Vision Technologies GmbH	Germany
Longoni, Milena	Image S SRL	Italy
Lüttmann, Dorothee	EMVA	Germany
Mangold, René	Photonfocus AG	Switzerland
Massen, Robert	MASSEN machine vision systems	Germany
Mehl, Hardy	Basler AG	Germany
Melder, Claus	SICK AG	Germany

Name	Company/Organisation	Country
Melis, Joachim	Adept Technology GmbH	Germany
Modrich, Kai-Udo	Fraunhofer IPA	Germany
Murphy, Patrick	Adept Technology Canada	Canada
OLLIVIER, Michel	EDIXIA	France
Ott, Emil	PCO AG	Germany
Pape, Katrin	National Instruments	Germany
Pelzer, Torsten	Viscom AG	Germany
Pluta, René	Philips	Netherlands
Pomrehn, Wolfgang	ASENTICS GmbH & Co. KG	Germany
Rauscher, Ernst	Rauscher GmbH	Germany
Reiner, Jacek	Wroclaw University of Technology	Poland
Roth, Barry	DALSA	Canada
ROUX, Bernard	VANNIER-PHOTELEC	France
Schaarschmidt, Andreas	STEMMER IMAGING GmbH	Germany
Schwarzkopf, Patrick	VDMA	Germany
Sgro, Joseph	Alacron, Inc.	USA
Simon, Thomas	Falcon-Vision Rt	Hungary
Soliman, Sayed	MaxxVision GmbH	Germany
Staerk, Henning	Allied Vision Technologies GmbH	Germany
Steenberg, Hans	Image House A/S	Denmark
Takaoka, Hiroshi	Tokyo Electronic Industry Co.,Ltd.	Japan
Tassakos, Lambis	inos-Automationssoftware GmbH	Germany
Terry, Nigel J.	Falcon-Vision Rt	Hungary
TRAOUAN, Viviane	EDIXIA	France
Trdic, Francel J	FDS Research	Slovenia
van Zeist, Gert	Vision Light Tech	Netherlands
Ventura, Antonio	DATAPIXEL	Spain
Visegrádi, Mihály	Magyar Elektronika	Hungary
Walter, Thomas	Stuttgarter Messe- und Kongress GmbH	Germany
Wány, Martin	AWAIBA	Switzerland
Wilkie, Tom	Imaging and Machine Vision Europe	United Kingdom
Yencharis, Leonard	Advanced Imaging Magazine	USA
Zoeller, Torsten	Cognex Inc.	Germany